

IN THE CLAIMS:

Please AMEND claim 14, as follows. Claim 14 is the only claim currently pending in this application.

14. (Currently Amended) A method for manufacturing a substrate having a fine line on a substrate face, said method comprising:

a fine-line forming step of forming the fine line on the substrate face, wherein a narrow-width portion is provided at an end portion of the fine line in a longitudinal direction, and the fine line is formed so that a width of the narrow-width portion in a parallel direction to the substrate face is smaller than a width of a portion adjacent to the narrow-width portion, and in a section of the fine line cut in the direction of a normal line on the face forming the fine line on the substrate, the section comprises a part which is away from the substrate-side-end of the section, and a length of a part of the section in the parallel direction to the substrate face is longer than a length of the substrate-side-end of the section in the parallel direction to the substrate face, said fine-line forming step comprising:

- (i) a step of providing a photosensitive material onto the substrate;
- (ii) a step of projecting light from above the substrate onto a predetermined region on the photosensitive material; and
- (iii) a ~~develop~~ developing step after said ~~light projection~~ step of projecting light.